SHIGA7.047APC PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Watanabe et al.

Appl. No. : 10/574,073

Filed : March 30, 2006

For : RESIST COMPOSITION FOR

ELECTRON BEAM OR EUV

Examiner : Walke, Amanda

Group Art Unit : 1752

AMENDMENT AND RESPONSE TO FINAL OFFICE ACTION

Mail Stop AF

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

In response to the final Office Action mailed **December 17**, **2007**, please amend the above-referenced application as follows:

Amendments to the Claims are reflected in the listing of claims, which begins on page 2 of this paper.

Remarks begin on page 6 of this paper.

OK TO ENTER: /ACW/